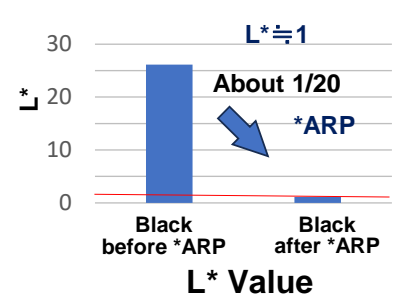
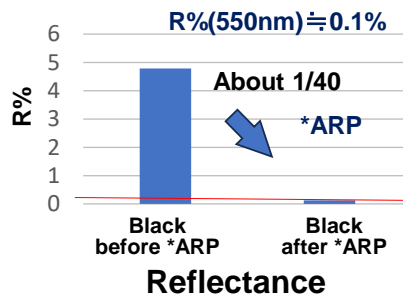
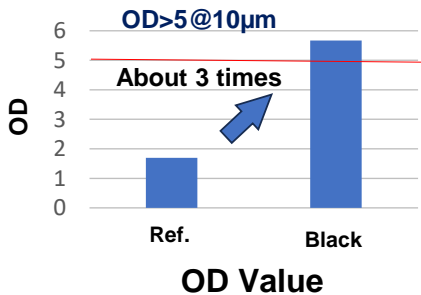




◆ Matte Black Coating

- ◆ Achieved High Light-shielding Inkjet Deposition Process with >OD 5.
- ◆ Further Anti-Reflection Process allowed us to achieve Reflectance 0.1% and L*1.

- Ink: Black Ink for IJP
- Substrate: Glass (□30mm)
- Thickness: 10μm
- Drop Volume: 30pL/drop



*ARP: Anti-Reflection Process

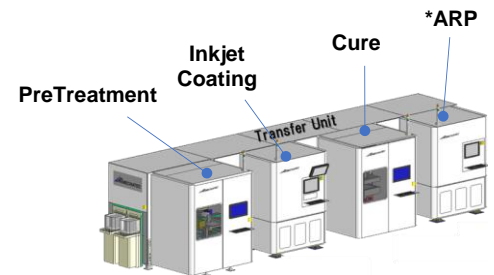
- ◆ Turnkey Process Solution covering multi-substrates Surface Modification, Coating, and Curing.

◆ Inkjet Process Features

- Flexible Form Printing and Unique Thickness Control
- Features Standard Material Gradient Coating Capability
- Standard Coating Control to suppress Coffee-Stain (Edge)

◆ Application

- For High-Performance Camera Modules, Lenses, and Prisms: Very Low Reflectance and High Light-Blocking Properties
- AR/VR: Enhanced Contrast and Reduced Stray Light through Partial Light Shielding
- Laser Light Source: High Light Shielding



Turnkey Process Unit

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